REPORT

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Meetings of the Working Circle on Directional SUBJECT

Semiconductors

East Germany

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REPORT NO.

The Circle on Directional Semiconductors

## THIS IS UNEVALUATED INFORMATION

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(Arbeitskreis fuer Richthalble in an initial stage. The Wd was directed by a strong and

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2. The transistors built at the Werk fuer Bauelemente der Nachrichten-Technik (plant for the construction of component parts of signal sourcement) (WRN) at Teltow the WBN was in a 25X1

position to manufacture up to 50 transisters per day.

3. The first conference of the was held on 17 January 196 Competition for the man of WBN and the Work fuer Mannafeld from Radeberg mes to adjudicate in the

The second conference of the Working Circle on Directional Semiconductors was held at Leipsig on 17 March 1955. The WF was represented by Dr. Boehn who stated that the quantity production of transistors had not yet been the WF plant and that only a small number of transistors was being b laboratory. The WBN plant was represented by Ir. Falter, Ir. Blankenb that their plant at Teltow was manufacturing 50 transistors per day and that these phaefer who stated transistors were being delivered to customers.

At the conference in Leipsig, it was resolved to order

transistors 25X1

for comparison measurements

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25X1 The third conference of the Working Circle was held in Radeberg on 25 March. The conference was attaided by the same engineers as the Leipzig conference. The problem

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